

## 06699 Atto 532

### Application

Atto 532 is a new label with high molecular absorption (115.000) and quantum yield (0.90) as well as sufficient stoke's shift (excitation maximum 532 nm, emission maximum 553 nm). It is optimised for excitation with frequency doubled Nd:YAG-Laser, and is characterized by high photo stability.

### Product Description

MW	765 g/Mol
$\epsilon$	115.000
$\eta_{fl}$	90%
Abs. max.:	532nm
Em. max.:	553 nm
$t_{F1}$	3.8 ns
Quantity	1 mg

